

OBJECTIVE

THERMAL CONDUCTIVITY AND WIEDMANN FRANZ LAW,

Carrier Diffusion

Diffusion current is due to the movement of the carriers from high concentration region towards to low concentration region. As the carriers diffuse, a diffusion current flows. The force behind the diffusion current is the *random thermal motion of carriers*.

$$\frac{dn}{dx} = \frac{1}{kT} \cdot \frac{dP}{dx}$$

A concentration gradient produces a pressure gradient which produces the force on the charge carriers causing to move them.

How can we produce a concentration gradient in a semiconductor?

- 1) By making a semiconductor or metal contact.
- 2) By illuminating a portion of the semiconductor with light.

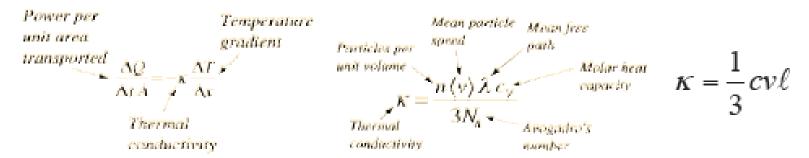
Illuminating a portion of the semiconductor with light

- ❖ By means of illumination, electron-hole pairs can be produced when the photon energy>E_{g.}
- ❖ So the increased number of electron-hole pairs move towards to the lower concentration region until they reach to their equilibrium values. So there is a number of charge carriers crossing per unit area per unit time, which is called as flux. Flux is proportional to the concentration gradient, dn/dx.

$$Flux = -D_n \frac{dn}{dx}$$

Thermal conductivity of metals

The thermal conductivity is given by:



- For the case of the Fermi gas: $C_{el} = \frac{1}{2}\pi^2 N_e k_B \cdot \frac{T}{T_F}$; $v = v_F$

$$\Rightarrow \kappa = \frac{\pi^2}{3} \cdot \frac{n_e k_B^2 T}{m v_F^2} \cdot v_F \cdot \ell = \frac{\pi^2 n_e k_B^2 T \tau}{3m}$$

Wiedemann-Franz's law

$$\frac{\kappa}{\sigma} = \frac{\pi^2 n_e k_B^2 T \tau / 3m}{n_e e^2 \tau / m} = \frac{\pi^2}{3} \left(\frac{k_B^2}{e}\right)^2 T$$